

Solar cell manufacture**ABSTRACT**

The present disclosure relates to a method of manufacturing a solar cell, the method comprising, in the order:

forming a tunnel oxide (52) over, at least, one surface of a semiconductor substrate (50);

forming a layer doped with a first-type conductive dopant over the tunnel oxide;

forming a mask (56) on the doped layer; and

performing, in a gas atmosphere (62) containing a second-type conductive dopant, doping at least one first region (66) of the doped layer using a laser.

Abstract figure: Fig. 26